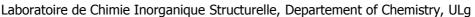
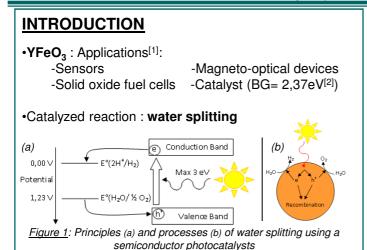


Thermal treatment and crystallization conditions of Yttrium Orthoferrite materials

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TECHNIQUE: Dip-Coating

Process

- Substrate immersion
- Deposition and removal •Dipping/Removal speed
- 3) Drain
- 4) Solvent evaporation
- Stabilization 5)

Parameters

- Substrate
- Relative humidity
- Stabilizing temperature

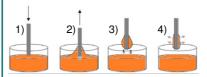


Figure 2: The different stages of the dip-coating method

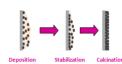
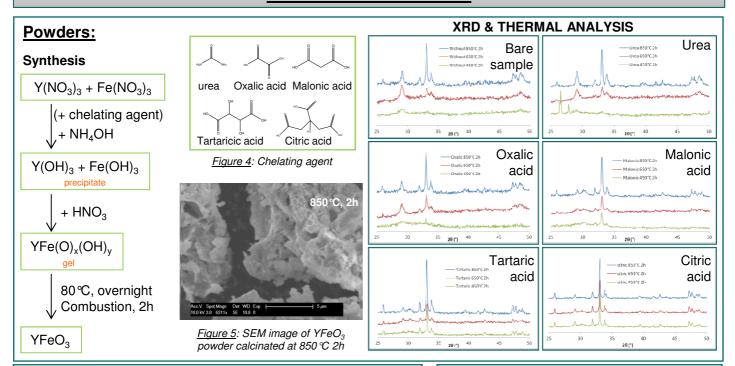
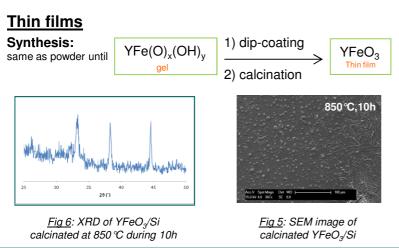


Figure 3: Particles repartition at different temperatures

RESULTS & DISCUSSIONS





Conclusions

- √Successfully synthesize YFeO₃ →Crystallization temperature: 850 °C
- √Successfully crystallize YFeO₃ on monocrystalline Si



At 850 °C, TCO melts...

- → Need to reduce the crystallization temperature
 - √ Chelating agent are useful →best one = Citric acid

^[1] Rajendran, M., Ghanashyam Krishna, M., Bhattacharya, A.K., Low temperature preparation of orthoferrite thin-films by an inorganic sol-gel process. Thin Solid Films 2001, 385, 230-233.

[2] Tang, Peisong; Sun, He; Chen, Haifeng; Cao, Feng, Hydrothermal Processing-Assisted Synthesis of Nanocrystalline YFeO3 and its Visible-Light Photocatalytic Activity, Current Nanoscience, Vol 8, Num 1, Feb 2012, pp. 64-67(4)